Nanoscale

PAPER

Cite this: Nanoscale, 2014, 6, 3618

Received 11th November 2013 Accepted 31st December 2013

DOI: 10.1039/c3nr05991j

www.rsc.org/nanoscale

1. Introduction

Graphene nanoresonators are promising candidates for ultrasensitive mass sensing and detection due to their desirable combination of high stiffness and a large surface area.¹⁻⁷ For such sensing applications, it is important that the nanoresonator exhibits low energy dissipation, or a high quality (*Q*)-factor, since the sensitivity of the nanoresonator is inversely proportional to its *Q*-factor.⁵ Various energy dissipation mechanisms have been explored in graphene nanoresonators, such as external attachment energy loss,^{8,9} intrinsic nonlinear scattering mechanisms,¹⁰ the effective strain mechanism,¹¹ edge effects,^{12,13} grain boundary-mediated scattering losses,¹⁴ and the adsorbate migration effect.¹⁵

Thanks to the recent experimental improvements in producing large-area, highly-pure samples of single and fewlayer graphene, several interesting experimental studies have been recently done on graphene nanoresonators. For example, at low temperature, extremely weak energy dissipation was

MoS₂ nanoresonators: intrinsically better than graphene?

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We perform classical molecular dynamics simulations to examine the intrinsic energy dissipation in singlelayer MoS₂ nanoresonators, where the point of emphasis is to compare their dissipation characteristics with those of single-layer graphene. Our key finding is that MoS₂ nanoresonators exhibit significantly lower energy dissipation, and thus higher quality (*Q*)-factors by at least a factor of four below room temperature, than graphene. Furthermore, this high *Q*-factor endows MoS₂ nanoresonators with a higher figure of merit, defined as frequency times *Q*-factor, despite a resonant frequency that is 50% smaller than that of graphene of the same size. By utilizing arguments from phonon–phonon scattering theory, we show that this reduced energy dissipation is enabled by the large energy gap in the phonon dispersion of MoS₂, which separates the acoustic phonon branches from the optical phonon branches, leading to a preserving mechanism for the resonant oscillation of MoS₂ nanoresonators. We further investigate the effects of tensile mechanical strain and nonlinear actuation on the *Q*-factors, where the tensile strain is found to counteract the reductions in *Q*-factor that occur with higher actuation amplitudes. Overall, our simulations illustrate the potential utility of MoS₂ for high frequency sensing and actuation applications.

observed in very pure graphene nanoresonators.¹⁶⁻¹⁸ However, these experiments also show that the energy dissipation increases substantially with increasing temperature for graphene nanoresonators, where theoretically it was found that the Q-factors decrease according to a 1/T scaling.¹² Furthermore, many sensing applications are expected to arise at temperatures approaching room temperature, and thus it is important and of practical significance to examine if other two-dimensional materials exhibit less intrinsic energy dissipation, which would be highly beneficial for applications that depend on two-dimensional nanoresonators.

Another two-dimensional material that has recently gained significant interest is molybdenum disulphide (MoS₂). The primary reason for the interest in MoS₂ is due to its superior electronic properties as compared to graphene, starting with the fact that in the bulk form it exhibits a band gap of around 1.2 eV,19 which can be further increased by changing its thickness,20 or through the application of mechanical strain.^{21,22} This finite band gap is the key reason for the interest in MoS₂ as compared to graphene due to the well-known fact that graphene is gapless.²³ Because of its direct band gap and also its well-known properties as a lubricant, MoS₂ has attracted considerable attention in recent years.^{24,25} For example, Radisavljevic et al.²⁶ demonstrated the potential of single-layer MoS₂ as a transistor. The strain and the electronic noise effects were found to be important for singlelayer MoS₂ transistors.²⁷⁻³⁰ Besides the electronic properties, there has also been increasing interest in the thermal and mechanical properties of mono and few-layer MoS2.31-38



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Very recently, two experimental groups have demonstrated the nanomechanical resonant behavior of single-layer MoS₂ (ref. 39) or few-layer MoS₂.⁴⁰ Interestingly, Lee *et al.* found that MoS₂ exhibits a higher figure of merit, *i.e.* frequency-*Q*-factor product $f_0 \times Q \approx 10^{10}$ Hz, than graphene.⁴⁰ While this experiment intriguingly suggests that MoS₂ may exhibit lower intrinsic energy dissipation than graphene, a systematic theoretical investigation and explanation for this fact is currently lacking. Therefore, the aim of the present work is to examine the intrinsic energy dissipation in MoS₂ nanoresonators, with comparison to graphene.

In doing so, we report for the first time that MoS_2 nanoresonators exhibit significantly less intrinsic energy dissipation, and also a higher figure of merit, than graphene. Furthermore, we find that the origin of this reduced energy dissipation is the large energy gap in the phonon dispersion of MoS_2 , which helps prevent the resonant oscillation from being deleteriously affected by other phonon modes. We also find that the energy dissipation in both MoS_2 and graphene nanoresonators is considerably enhanced when larger actuation amplitudes are prescribed due to the emergence of ripples. However, we also show that these ripples can be removed and the enhanced energy dissipation can be mitigated through the application of tensile mechanical strain.

2. Structure and simulation details

The single-layer graphene and single-layer MoS_2 samples in our simulation are 200 Å in the longitudinal direction and 20 Å in the lateral direction. The interaction between carbon atoms in graphene is described by the Brenner (REBO-II) potential.⁴¹ The interaction within MoS_2 is described by the recently developed Stillinger–Weber potential.³⁷ The standard Newton equations of motion are integrated in time using the velocity Verlet algorithm with a time step of 1 fs. Both ends in the longitudinal direction are fixed while periodic boundary conditions are applied in the lateral direction.

Our simulations are performed as follows. First, the Nosé-Hoover^{42,43} thermostat is applied to thermalize the system to a constant temperature within the NPT (i.e. the number of particles N, the pressure P and the temperature T of the system are constant) ensemble, which is run for 100 ps. Free mechanical oscillations of the nanoresonators are then actuated by adding a sine-shaped velocity distribution to the system in the z direction,¹³ where the z direction is perpendicular to the graphene or MoS₂ plane. The imposed velocity for atom *i* is $\vec{v}_i = \beta \sin (\pi x_i/L)\vec{e}_z$. The actuation parameter β determines the resonant oscillation amplitude, $A = \beta/\omega$, where $\omega = 0.25$ or 0.5 ps⁻¹ is the angular frequency of the graphene and MoS₂ nanoresonators in the present work. For $\beta = 1.0$ Å ps⁻¹, the resonant oscillation amplitude is 2 Å for graphene and 4.0 Å for MoS₂, which is only 1% or 2% of the length of the resonator. The corresponding effective strain is 0.037% for MoS₂.¹¹

After the actuation of the mechanical oscillation, the system is allowed to oscillate freely within the *NVE* (*i.e.* the particle number N, the volume V and the energy E of the system are constant) ensemble. The data from this *NVE* ensemble are used to analyze the mechanical oscillation of the nanoresonators. All molecular dynamics simulations were performed using the publicly available simulation code LAMMPS,^{44,45} while the OVITO package was used for visualization.⁴⁶

3. Results and discussion

3.1. Lower intrinsic energy dissipation in MoS₂ than that in graphene nanoresonators

We first compare the temperature dependence of the intrinsic energy dissipation in the single-layer graphene and MoS₂ nanoresonators. Fig. 1 shows the kinetic energy time history in both graphene (left) and MoS₂ (right) nanoresonators when the actuation energy parameter $\beta = 2.0$. The oscillation amplitude of the kinetic energy decays gradually, which reflects the dissipation of the resonant oscillation energy within the nanoresonator. A common feature in the graphene¹² and MoS₂ nanoresonators is that the energy dissipation becomes larger with increasing temperature.

Fig. 2(a) shows the *Q*-factor extracted from the kinetic energy time history shown in Fig. 1 for both graphene and MoS₂. The decay of the oscillation amplitude of the kinetic energy is used to extract the *Q*-factor by fitting the kinetic energy from the *NVE* ensemble to a function $E_k(t) = a + b(1 - 2\pi/Q)^t \cos(\omega t)$, where ω is the frequency, *a* and *b* are two fitting parameters and *Q* is the resulting quality factor.¹³ The *Q*-factor of MoS₂ is clearly higher



Fig. 1 Kinetic energy time history in graphene (left) and MoS₂ (right) nanoresonators at different temperatures. The actuation parameter $\beta = 2$ for all calculations here. Left: the energy dissipation in graphene nanoresonators increases quickly with increasing temperature. Right: the energy dissipation in MoS₂ nanoresonators increases slowly with increasing temperature, and thus the MoS₂ nanoresonator exhibits a lower intrinsic energy dissipation than the graphene nanoresonator at the same temperature.



Fig. 2 Temperature dependence of the (a) *Q* factor and (b) figure of merit (*i.e.* $f_0 \times Q$) for graphene and MoS₂ nanoresonators. The actuation parameter $\beta = 2$ for all calculations here.

than that of graphene, and is greater by at least a factor of four for all temperatures below room temperature. In particular, the *Q*-factor at room temperature for MoS₂ is 327 from our simulations, which is much higher than the *Q*-factor of 83 for graphene as extrapolated from the fitting formula. Fig. 2(a) also shows that the *Q*-factors of single-layer MoS₂ decay with temperature according to a $Q \sim 1/T^{-1.3}$ relationship, similar to the $Q \sim 1/T^{-1.2}$ relationship we find for single-layer graphene, where the $T^{-1.2}$ relationship we report is slightly different than the T^{-1} relationship found previously by Kim and Park¹² due to differences in how the *Q*-factor was calculated.

Fig. 2(b) compares the figure of merit (*i.e.* $f_0 \times Q$) for graphene and MoS₂ nanoresonators. The figure of merit for MoS₂ is also higher than that for graphene although the frequency for MoS₂ (40 GHz) is only half of the frequency for graphene (80 GHz), which again is due to the substantially higher *Q*-factors for MoS₂ nanoresonators.

To understand the energy dissipation in graphene and MoS_2 nanoresonators, we shall analyze the relationship between the mechanical resonant oscillation in the nanoresonator and the phonon modes in the lattice dynamics theory. The resonant oscillation of these two-dimensional structures is actually the mechanical vibration of their out of plane (*z*)-direction acoustic (ZA) modes, so the only energy dissipation mechanism here is due to phonon–phonon scattering.⁴⁷ This ZA mode is scattered by other phonon modes, which have higher density of states at higher temperature. As a result, the scattering of the ZA mode becomes stronger with increasing temperature. This is the

origin of the increase in energy dissipation with increasing temperature observed in Fig. 1. It should be noted that boundary scattering does not play a role here, because there is no temperature gradient in the simulation of the resonant oscillation. The system has been thermalized to a constant temperature within the *NPT* ensemble prior to the actuation of the mechanical oscillation. As a result, the flexural phonons are not transported to the boundary of the system. Instead, the flexural phonon acts as a stationary mode in the system.

From Fig. 1, it is obvious that the MoS_2 nanoresonator exhibits much smaller energy dissipation than the graphene nanoresonator at the same temperature, where the difference becomes more distinct with increasing temperature.

To reveal the underlying mechanism for this difference, we first identify and discuss some fundamental phonon modes in graphene and MoS₂, because phonon–phonon scattering is the only energy dissipation mechanism that is operant here. Specifically, there are three acoustic branches, *i.e.* the ZA branch, the transverse acoustic (TA) branch, and the longitudinal acoustic (LA) branch. There are also three optical branches, *i.e.* the z-direction optical (ZO) branch, the transverse optical (LO) branch, and the longitudinal optical (LO) branch.

Fig. 3 shows the phonon dispersion of single-layer graphene and MoS_2 along the high symmetry ΓKM lines in the Brillouin zone. Fig. 3(a) shows the phonon dispersion of graphene calculated from the Brenner potential.⁴¹ The three acoustic branches are plotted by blue solid lines. The three optical



Fig. 3 Phonon dispersion of graphene and MoS_2 along the high symmetry Γ KM lines in the Brillouin zone. (a) Phonon dispersion of graphene calculated from the Brenner potential. Note the crossing of the acoustic and optical branches. (b) Phonon dispersion of MoS_2 calculated from the Stillinger–Weber potential. Note the clear energy gap (gray area) between the acoustic and optical branches, *i.e.* there is no cross-over between the acoustic and optical branches.

branches are plotted by red solid lines. The key feature is the fact that the acoustic and optical branches exhibit a cross-over, where this cross-over is a general feature in the phonon dispersion curves for single-layer graphene obtained from different methods, *e.g.* the force constant model,⁴⁸ first-principles calculations,⁴⁹ or experiments.⁴⁹⁻⁵¹

Fig. 3(b) shows the phonon dispersion of single-layer MoS₂ calculated from the Stillinger–Weber potential.³⁷ In contrast to graphene, there is an energy gap (gray area) between the acoustic and optical branches, *i.e.* there is no cross-over between the acoustic and optical branches. This is again a general feature in the phonon dispersion curves of MoS₂ obtained from different methods, *e.g.* the force constant model,^{52,53} first-principles calculations,⁵⁴ or experiments.⁵⁵ The key effect of this energy gap is to separate the acoustic phonon branches from the optical phonon branches in single-layer MoS₂.

The strength of the phonon-phonon scattering is simultaneously determined by two aspects. First, it is proportional to the square of the nonlinear elastic constant. The nonlinear elastic constant of MoS₂ is about -1.8 TPa from the Stillinger-Weber potential used in our simulation, which is close to the value of -2.0 TPa in graphene.^{2,4} Secondly, the symmetry selection rule plays a key role in determining the strength of the phonon-phonon scattering. In the phonon-phonon scattering mechanism, the symmetric selection rule requires phonon modes from different branches to be involved.56,57 A typical scattering process is shown in Fig. 4(a), where the ZA mode is scattered by the other acoustic modes LA (or TA). As a result of this phonon-phonon scattering, another optical mode ZO (or LO, or TO) is created. The energy and momentum conservation laws add two strict constraints on the phonon-phonon scattering process, *i.e.* $q_{ZA} + q_{LA} = q_{ZO}$ and $\omega_{ZA} + \omega_{LA} = \omega_{ZO}$. We note that this corresponds to the normal phonon-phonon scattering process. The Umklapp scattering is another phonon-phonon scattering process, where the momentum conservation is relaxed by allowing the appearance of a reciprocal lattice vector.56 Our discussions here are also applicable for the Umklapp process.

Fig. 4(b) shows the phonon-phonon scattering of a lowfrequency ZA mode in graphene, where both energy and momentum constraints are satisfied. We have chosen a particular ZA mode with ($q_{\rm ZA}$, $\omega_{\rm ZA}$) from the ZA branch (blue solid line). The origins of the TA and LA branches (black dashed lines) are shifted to the position of this ZA mode. In this way, the crossing point between TA/LA and the optical branches will disclose all permitted phonon-phonon scattering processes (i.e. with conserved energy and momentum). There are four cross-over points (green circles) between TA/LA and the optical branches (red solid lines). These four crossing points correspond to four permitted phonon-phonon scattering processes in single-layer graphene. In the horizontal axis, we have depicted the corresponding wave vectors of the three phonon modes for a crossing between the LA and ZO branches, *i.e.* $q_{ZA} + q_{LA} = q_{ZO}$. The energy conservation is analogous.

Different from graphene, Fig. 4(c) shows that there is no crossing between the TA/LA branches and the optical branches in MoS₂, because of the energy gap between acoustic and optical



Fig. 4 Illustration of the phonon–phonon scattering mechanism in the graphene and MoS₂ nanoresonators. (a) A typical scattering process. The ZA mode is scattered by the other acoustic LA mode. As a result of this phonon–phonon scattering, one optical ZO mode is created. The energy and momentum constraints are: $q_{ZA} + q_{LA} = q_{ZO}$ and $\omega_{ZA} + \omega_{LA} = \omega_{ZO}$. (b) The phonon–phonon scattering of a lowfrequency ZA mode (q_{ZA} , ω_{ZA}) in graphene, where both energy and momentum constraints are satisfied. The origins of the TA and LA branches (black dashed lines) are shifted to the position of this ZA mode. There are four cross-over points (green circles) between TA/LA and the optical branches (red solid lines), which correspond to four permitted phonon–phonon scattering processes. (c) There is no cross-over between the shifted TA/LA branches and the optical branches in MoS₂, because of the energy gap between the acoustic and optical branches.

branches. This indicates that there is no permitted scattering for the ZA mode in MoS_2 , which has the important implication that the resonant oscillation in MoS_2 can occur for a long time with less intrinsic energy dissipation. In other words, the energy gap between acoustic and optical branches in MoS_2 helps to prevent the resonant oscillation from being interrupted by other vibrational modes, and that is why MoS_2 nanoresonators exhibit significantly less energy dissipation than graphene nanoresonators.

We note that a similar energy gap also exists in the phonon dispersion of other dichalcogenides like WS₂.^{53,54} Based on the above discussion, these materials are also expected to have less intrinsic energy dissipation than graphene nanoresonators.

3.2. Nonlinear and strain effects

In addition to studying the differences in intrinsic energy dissipation, we now study additional effects that have previously been used to tailor, or enhance the resonant properties of graphene nanoresonators. For example, recent studies have shown that inducing large, nonlinear oscillations of graphene may lead to an increased mass sensitivity.^{11,58,59} Similarly, researchers have shown that the application of tensile mechanical strain can substantially increase the *Q*-factors, and thus the mass sensitivity of graphene.⁶⁰ The issue we consider now is the utility of these techniques on MoS₂ nanoresonators.

Fig. 5 shows that the energy dissipation can be affected by the actuation parameter β . Fig. 5 compares the kinetic energy time history in graphene and MoS₂ nanoresonators at T = 4.2 K. It shows that the energy dissipation in both systems becomes stronger as the actuation parameter increases. This is because of the nonlinear interaction between the oscillation mode and other vibration modes in the graphene or MoS₂ induced by the large actuation parameter; *i.e.* the graphene or MoS₂ nanoresonator is stretched so much in the sine-wave-like configuration that it cannot contract back to its original length after it reaches the horizontal position. As a result, some obvious ripples occur in the configuration with maximum kinetic energy as shown in the two insets for $\beta = 5$ panels. These two insets show two special configurations, which have minimum or maximum kinetic energy. A direct result from these ripples is the generation of other z-direction vibration modes, leading to the decoherence of the resonant oscillation. This decoherence effect results in stronger energy dissipation in the graphene and MoS_2 nanoresonators actuated by a large β parameter. This is similar to the effect that an initial slack has in degrading the *Q*-factors of graphene nanoresonators. Garcia-Sanchez *et al.* found that an initial slack leads to a specific vibrational mode that is localized at the free edges of the graphene nanoresonator. In these vibrations, graphene vibrates in the perpendicular direction; *i.e.* in the same direction as the nanomechanical oscillation direction. As a result, the nanomechanical resonant oscillation of graphene will be affected by these edge vibrations, leading to a lower *Q*-factor.⁶¹

Fig. 6 (left) shows that the energy dissipation in graphene can effectively be eliminated through the application of tensile mechanical strain. These results were obtained from Fig. 6 using the simulation parameters of T = 50.0 K and $\beta = 2.0$. For the graphene nanoresonator, the energy dissipation is minimized by applying tensile strains larger than $\varepsilon = 0.01$, or 1%, which has previously been observed by Kim and Park.⁹ The energy dissipation in MoS₂ nanoresonators can also be reduced by the tensile strain. (see the right panel in Fig. 6), though we note that the *Q*-factors of graphene are more strongly enhanced by strain as they are significantly smaller without any applied strain.

To understand the effects of tensile strain on the energy dissipation, we monitor the structural evolution from the molecular dynamics simulation for both graphene and MoS₂.

graphene

ε=0.00

11

MoS₂

ε=0.00





Fig. 5 Kinetic energy time history for graphene (left) and MoS₂ (right) nanoresonators with different actuation parameters β . Temperature T = 4.2 K for this set of calculations. In both graphene and MoS₂ nanoresonators, the energy dissipation increases with increasing actuation parameter β . The insets show two special configurations from an early stage of molecular dynamics simulation, which correspond to minimum or maximum kinetic energy. Ripples are indicated by green ellipses.

Fig. 6 Kinetic energy time history for graphene (left) and MoS₂ (right) nanoresonators with different mechanical tensions ε . Temperature T = 50 K and actuation parameter $\beta = 2.0$ for this set of simulations. The mechanical strain strongly alleviates the energy dissipation in graphene nanoresonators, while having a less pronounced effect on MoS₂, though the intrinsic dissipation in MoS₂ is much smaller than that in graphene.



Fig. 7 Configurations for graphene and MoS₂ nanoresonators from an early stage of the molecular dynamics simulation at T = 50.0 K and $\beta = 2.0$. (a)–(c) are configurations of graphene nanoresonators with increasing mechanical tension. Two special configurations, which correspond to minimum or maximum kinetic energy, are shown. In (a), some ripples (indicated by green ellipses) can be found in the (horizontal) configuration with maximum kinetic energy, as a result of the thermal vibration of graphene. These ripples in the graphene nanoresonator can be removed by mechanical tension as shown in (b) and (c). (d)–(f) are configurations for MoS₂ nanoresonators with increasing mechanical tension. Ripples in the MoS₂ nanoresonator are not present due to a large bending modulus of MoS₂.

Fig. 7 shows two special configurations corresponding to minimum or maximum kinetic energy, for graphene (left) and MoS_2 nanoresonators (right). Panels Fig. 7(a)–(c) are configurations of graphene nanoresonators with increasing mechanical tension. Panel Fig. 7(a) shows some obvious ripples (indicated by green ellipses) in the horizontal configuration, i.e. with maximum kinetic energy. These ripples are the result of thermal vibrations at 50 K, and they occur because it is energetically much easier for graphene to bend than to deform in-plane. These ripples are smaller than those generated due to large actuation energy as shown in Fig. 5. As we have mentioned above, the function of ripples is to generate other z-direction vibrational modes, leading to stronger energy dissipation in the graphene nanoresonator. Panels Fig. 7(b) and (c) show that these thermal vibration induced ripples in the graphene nanoresonator can be completely eliminated by the mechanical tension, as the graphene nanoresonator recovers its original horizontal shape at its maximum kinetic energy state. That is the origin of the decreasing energy dissipation by tensile strain in graphene nanoresonators in Fig. 6. Fig. 7(d)-(f) are configurations for MoS₂ nanoresonators with increasing mechanical tension. The thermal vibration-induced rippling is effectively not observed in the MoS₂ nanoresonator, mainly due to its large bending modulus as compared with graphene.38 These small ripples are also completely eliminated by the mechanical strains we applied, leading again to reduced energy dissipation in MoS_2 as seen in Fig. 6.

Finally, it should be noted that the system size in our simulation is substantially smaller than would typically be examined in experiments. An interesting open issue is to address the dimensional crossover in the MoS_2 nanoresonators, where the oscillation-induced local strain close to the clamped boundary is known to have an important effect.^{62,63}

4. Conclusion

In conclusion, we have utilized classical molecular dynamics simulations to compare the intrinsic energy dissipation in singlelayer MoS₂ nanoresonators to that in single-layer graphene nanoresonators. Our key finding is that the energy dissipation in MoS₂ nanoresonators is considerably less than in graphene nanoresonators for the same conditions, endowing MoS₂ with both higher Q-factors and figure of merit as compared to graphene nanoresonators. Based on the phonon-phonon scattering mechanism, we attribute the reduced energy dissipation in MoS₂ to the large energy gap in its phonon dispersion, which helps to prevent the resonant oscillation from being interrupted by other vibrational modes. This energy gap in the phonon dispersion is also observed in other dichalcogenides, such as WS2, which suggests that this class of materials may generally exhibit lower energy dissipation and higher Q-factors as nanoresonators. We also demonstrate that nonlinear actuation leads to larger energy dissipation in MoS₂ as compared to graphene due to the existence of additional ripples in MoS₂, though tensile mechanical strain is effective in reducing the energy dissipation in both graphene and MoS₂.

Acknowledgements

This work is supported by the Recruitment Program of Global Youth Experts of China and the German Research Foundation (DFG). HSP acknowledges the support from the mechanical engineering department at Boston University.

References

1 J. S. Bunch, A. M. van der Zande, S. S. Verbridge, I. W. Frank, D. M. Tanenbaum, J. M. Parpia, H. G. Craighead and P. L. McEuen, *Science*, 2007, **315**, 490.

- 2 C. Lee, X. Wei, J. W. Kysar and J. Hone, *Science*, 2008, **321**, 385.
- 3 J.-W. Jiang, J.-S. Wang and B. Li, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2009, **80**, 113405.
- 4 J.-W. Jiang, J.-S. Wang and B. Li, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2010, **81**, 073405.
- 5 K. L. Ekinci and M. L. Roukes, *Rev. Sci. Instrum.*, 2005, 76, 061101.
- 6 J. Arlett, E. Myers and M. Roukes, *Nat. Nanotechnol.*, 2011, 6, 203.
- 7 K. Eom, H. S. Park, D. S. Yoon and T. Kwon, *Phys. Rev.*, 2011, 503, 115.
- 8 C. Seoánez, F. Guinea and A. H. C. Neto, *Phys. Rev. B:* Condens. Matter Mater. Phys., 2007, 76, 125427.
- 9 S. Y. Kim and H. S. Park, Appl. Phys. Lett., 2009, 94, 101918.
- 10 J. Atalaya, A. Isacsson and J. M. Kinaret, *Nano Lett.*, 2008, **8**, 4196.
- 11 J.-W. Jiang, H. S. Park and T. Rabczuk, *Nanotechnology*, 2012, 23, 475501.
- 12 S. Y. Kim and H. S. Park, Nano Lett., 2009, 9, 969.
- 13 J.-W. Jiang and J.-S. Wang, J. Appl. Phys., 2012, 111, 054314.
- 14 Z. Qi and H. S. Park, Nanoscale, 2012, 4, 3460.
- 15 J.-W. Jiang, B.-S. Wang, H. S. Park and T. Rabczuk, *Nanotechnology*, 2014, **25**, 025501.
- 16 A. Eichler, J. Moser, J. Chaste, M. Zdrojek, I. Wilson-Rae and A. Bachtold, *Nat. Nanotechnol.*, 2011, **6**, 339.
- 17 A. M. van der Zande, R. A. Barton, J. S. Alden, C. S. Ruiz-Vargas, W. S. Whitney, P. H. Q. Pham, J. Park, J. M. Parpia, H. G. Craighead and P. L. McEuen, *Nano Lett.*, 2010, 10, 4869.
- 18 C. Chen, S. Rosenblatt, K. I. Bolotin, W. Kalb, P. Kim, I. Kymissis, H. L. Stormer, T. F. Heinz and J. Hone, *Nat. Nanotechnol.*, 2009, 4, 861.
- 19 K. K. Kam and B. A. Parkinson, J. Phys. Chem., 1982, 86, 463.
- 20 K. F. Mak, C. Lee, J. Hone, J. Shan and T. F. Heinz, *Phys. Rev. Lett.*, 2010, **105**, 136805.
- 21 J. Feng, X. Qian, C. Huang and J. Li, *Nat. Photonics*, 2012, 6, 866.
- 22 P. Lu, X. Wu, W. Guo and X. C. Zeng, *Phys. Chem. Chem. Phys.*, 2012, **14**, 13035.
- 23 K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, M. I. Katsnelson, I. V. Grigorieva, S. V. Dubonos and A. A. Firsov, *Nature*, 2005, 438, 197.
- 24 Q. H. Wang, K. Kalantar-Zadeh, A. Kis, J. N. Coleman and M. S. Strano, *Nat. Nanotechnol.*, 2012, 7, 699.
- 25 M. Chhowalla, H. S. Shin, G. Eda, L. Li, K. P. Loh and H. Zhang, *Nat. Chem.*, 2013, 5, 263.
- 26 B. Radisavljevic, A. Radenovic, J. Brivio, V. Giacometti and A. Kis, *Nat. Nanotechnol.*, 2011, **6**, 147.
- 27 H. J. Conley, B. Wang, J. I. Ziegler, R. F. Haglund, S. T. Pantelides and K. I. Bolotin, *Nano Lett.*, 2013, 13, 3626.
- 28 V. K. Sangwan, H. N. Arnold, D. Jariwala, T. J. Marks, L. J. Lauhon and M. C. Hersam, *Nano Lett.*, 2013, 13, 4351.
- 29 M. Ghorbani-Asl, N. Zibouche, M. Wahiduzzaman, A. F. Oliveira, A. Kuc and T. Heine, *Sci. Rep.*, 2013, **3**, 2961.

- 30 T. Cheiwchanchamnangij, W. R. L. Lambrecht, Y. Song and H. Dery, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2013, **88**, 155404.
- 31 W. Huang, H. Da and G. Liang, J. Appl. Phys., 2013, 113, 104304.
- 32 V. Varshney, S. S. Patnaik, C. Muratore, A. K. Roy, A. A. Voevodin and B. L. Farmer, *Comput. Mater. Sci.*, 2010, **48**, 101.
- 33 S. Bertolazzi, J. Brivio and A. Kis, ACS Nano, 2011, 5, 9703.
- 34 R. C. Cooper, C. Lee, C. A. Marianetti, X. Wei, J. Hone and J. W. Kysar, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2013, 87, 035423.
- 35 R. C. Cooper, C. Lee, C. A. Marianetti, X. Wei, J. Hone and J. W. Kysar, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2013, 87, 079901.
- 36 J.-W. Jiang, X.-Y. Zhuang and T. Rabczuk, *Sci. Rep.*, 2013, 3, 2209.
- 37 J.-W. Jiang, H. S. Park and T. Rabczuk, J. Appl. Phys., 2013, 114, 064307.
- 38 J.-W. Jiang, Z. Qi, H. S. Park and T. Rabczuk, *Nanotechnology*, 2013, **24**, 435705.
- 39 A. Castellanos-Gomez, R. van Leeuwen, M. Buscema, H. S. J. van der Zant, G. A. Steele and W. J. Venstra, *Adv. Mater.*, 2013, 25, 6719–6723.
- 40 J. Lee, Z. Wang, K. He, J. Shan and P. X.-L. Feng, *ACS Nano*, 2013, 7, 6086.
- 41 D. W. Brenner, O. A. Shenderova, J. A. Harrison, S. J. Stuart, B. Ni and S. B. Sinnott, *J. Phys.: Condens. Matter*, 2002, 14, 783.
- 42 S. Nose, J. Chem. Phys., 1984, 81, 511.
- 43 W. G. Hoover, Phys. Rev. A, 1985, 31, 1695.
- 44 S. J. Plimpton, J. Comput. Phys., 1995, 117, 1.
- 45 Lammps, http://www.cs.sandia.gov/~sjplimp/lammps.html, 2012.
- 46 A. Stukowski, Modell. Simul. Mater. Sci. Eng., 2010, 18, 015012.
- 47 J.-W. Jiang, J.-S. Wang and B. Li, *Europhys. Lett.*, 2010, **89**, 46005.
- 48 R. Saito, G. Dresselhaus and M. S. Dresselhaus, *Physical Properties of Carbon Nanotubes*, 1998.
- 49 J. Maultzsch, S. Reich, C. Thomsen, H. Requardt and P. Ordejon, *Phys. Rev. Lett.*, 2004, **92**, 075501.
- 50 T. Aizawa, R. Souda, S. Otani and Y. Ishizawa, *Phys. Rev. B:* Condens. Matter Mater. Phys., 1990, 42, 11469.
- 51 M. Mohr, J. Maultzsch, E. Dobardzic, S. Reich, I. Milosevic, M. Damnjanovic, A. Bosak, M. Krisch and C. Thomsen, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2007, 76, 035439.
- 52 S. Jimenez Sandoval, D. Yang, R. F. Frindt and J. C. Irwin, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1991, 44, 3955.
- 53 M. Damnjanovic, E. Dobardzic, I. Miloeevic, M. Virsek and M. Remskar, *Mater. Manuf. Processes*, 2008, 23, 579.
- 54 A. Molina-Sánchez and L. Wirtz, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2011, **84**, 155413.
- 55 N. Wakabayashi, H. G. Smith and R. M. Nicklow, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1975, **12**, 659.
- 56 M. Born and K. Huang, *Dynamical Theory of Crystal Lattices*, Oxford University Press, Oxford, 1954.

Paper

- 57 M. G. Holland, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1963, **132**, 2461.
- 58 M. D. Dai, K. Eom and C.-W. Kim, *Appl. Phys. Lett.*, 2009, **95**, 203104.
- 59 J. Atalaya, J. M. Kinaret and A. Isacsson, *Europhys. Lett.*, 2010, **91**, 48001.
- 60 S. Y. Kim and H. S. Park, *Nanotechnology*, 2010, **21**, 105710.
- 61 D. Garcia-Sanchez, A. M. van der Zande, A. S. Paulo,B. Lassagne, P. L. McEuen and A. Bachtold, *Nano Lett.*, 2008, 8, 1399.
- 62 Q. P. Unterreithmeier, T. Faust and J. P. Kotthaus, *Phys. Rev. Lett.*, 2010, **105**, 027205.
- 63 R. A. Barton, B. Ilic, A. M. van der Zande, W. S. Whitney,
 P. L. M. J. M. Parpia and H. G. Craighead, *Nano Lett.*, 2011, 11, 1232.